<table>
<thead>
<tr>
<th>AUTHORS</th>
<th>TITLE</th>
</tr>
</thead>
<tbody>
<tr>
<td>R.A. Rogio, M.R. Vasquez Jr.</td>
<td>Effects on germination and seedling growth of mung beans (Vigna radiata L. Wilczek) via RF plasma modification of seed coat</td>
</tr>
<tr>
<td>C.M.D. Cagomoc, M.R. Vasquez Jr.</td>
<td>Plasma modification of natural zeolite for chromium adsorption</td>
</tr>
<tr>
<td>A.S.M. Ebuen, M.R. Vasquez Jr.</td>
<td>Growth of copper oxide films on stainless steel through thermal evaporation of copper for antibacterial surface applications</td>
</tr>
<tr>
<td>S.J. Park, C.L.S. Mahinay, I.B. Culaba</td>
<td>A study of the sustained hydrophilic property of atmospheric pressure plasma jet treated PMMA</td>
</tr>
<tr>
<td>K. Nakamura, S. Gotoh, J. Yamada, M. Wada</td>
<td>Evacuation system for testing electronics components at a rapidly temperature changing condition</td>
</tr>
<tr>
<td>M.R. Vasquez Jr., R. Flauta</td>
<td>Batch and strip-type plasma cleaning configurations and its applications for IC packaging technologies</td>
</tr>
<tr>
<td>K.L.M. Taaca, M.R. Vasquez Jr.</td>
<td>Fabrication and characterization of plasma-modified chitosan/Ag-exchanged zeolite composite</td>
</tr>
<tr>
<td>J.R.Y. Uy, A.R.Y. Centeno, M.D.L. Balela, R.B. Tumlos, J.P.R. Ferrolino</td>
<td>Synthesis of ZnO on glass via microwave-assisted chemical bath deposition</td>
</tr>
<tr>
<td>M.N.R. Gilos, M.R. Vasquez Jr.</td>
<td>Optical properties of anodized copper films on glass substrates</td>
</tr>
<tr>
<td>E.J.C. Tinacba, J.A.P. Nuñez, R.B. Tumlos, H.J. Ramos</td>
<td>Photo-catalytic degradation of Rhodamine 6G dye by ZnO film deposited using microwave atmospheric plasma jet</td>
</tr>
<tr>
<td>H.S. Salapare III</td>
<td>The state of surface and interface science research in the Philippines</td>
</tr>
<tr>
<td>A.R.Y. Centeno, M.D.L. Balela, R.B. Tumlos</td>
<td>Ar-air plasma treatment of polypropylene sheets via microwave atmospheric plasma pen</td>
</tr>
<tr>
<td>M.J.D. De Leon, M.R. Vasquez Jr.</td>
<td>Effect of plasma treatment on the morphology of silicon substrates</td>
</tr>
<tr>
<td>B.A. Cabauatan, M.R. Vasquez Jr.</td>
<td>Effects of argon plasma treatment on the morphology of FTO glass</td>
</tr>
</tbody>
</table>